

Low-Power Analog IC Design Activities at CNM

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- 1 Introduction
- 2 Sensor Signal Processors
- 3 Low-Cost Imagers
- 4 RF Transceivers
- 5 Implantable Systems
- 6 Future

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Skills

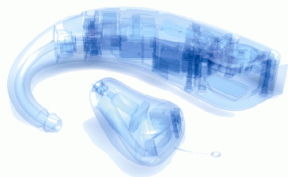
- ▶ Wide experience on **R+D/industrial** IC applications
- ▶ Deep **CMOS** technology knowledge
- ▶ Advanced MOS device **modeling**
- ▶ State-of-the-art **analog/mixed/RF circuit** techniques
- ▶ **System-on-Chip** development
- ▶ **Full-custom** sub-micron IC design
- ▶ **Custom test** capabilities

Environment

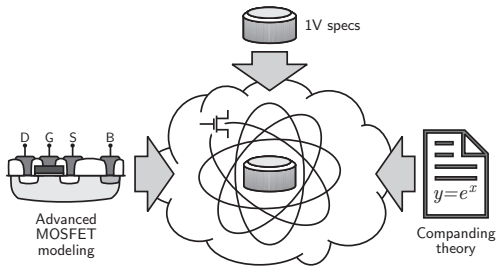
- ▶ In-house: state-of-the-art **nanotechnology**
basic **CMOS** technology
advanced hybrid **MCM** packaging
- ▶ Full access to **Europractice/Mosis** programs
- ▶ Wide variety of supported **CAD** workflows
- ▶ High-value **equipment** facilities
- ▶ Good interaction between design/technology **staff**
- ▶ Experience on **funding** strategies
- ▶ Many other research lab **partners**

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Hearing Aids



- ▶ Small battery: **1.0V** + **<0.5mA**
- ▶ Small package: **<10mm²** + few components
- ▶ Complex audio processing
- ▶ Large dynamic range: **>70dB**
- ▶ Low-cost: **CMOS** + program. BTE...CIC



True-1V analog operation
using novel
subthreshold log-domain
circuit techniques

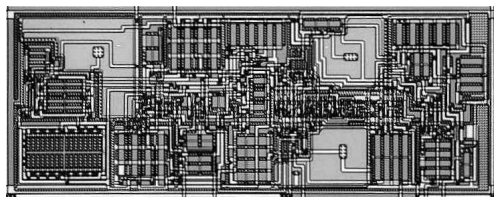
Hearing Aids

▶ Library driven research:

- ▶ Pre-amplification
- ▶ Dual-AGC
- ▶ Arbitrary filtering
- ▶ PDM conversion
- ▶ Class-D output
- ▶ Built-in references
- ▶ Digitally programmable

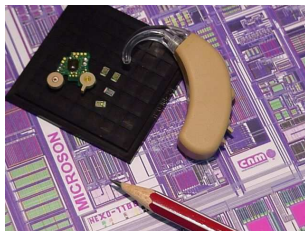
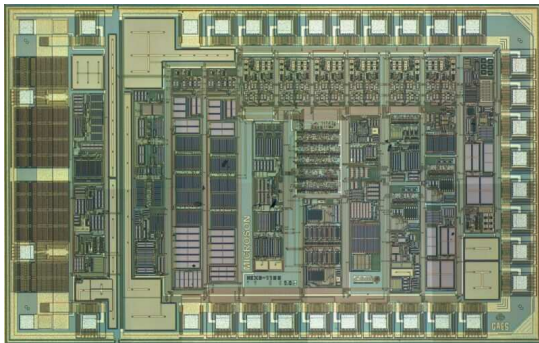
1997-99 **CICYT-TIC97-1159**
*Low-Power and Low-Voltage
Microelectronics for
Hearing-Aids*

1998-00 **ESPRIT-FUSE-23068**
*Microelectronic Device for
Hearing Aid Application*



Hearing Aids

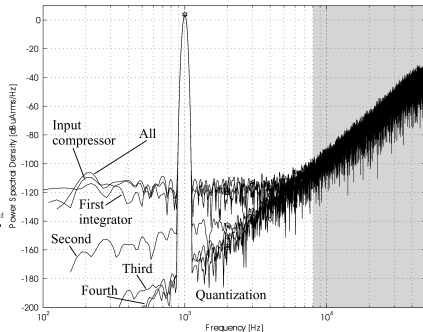
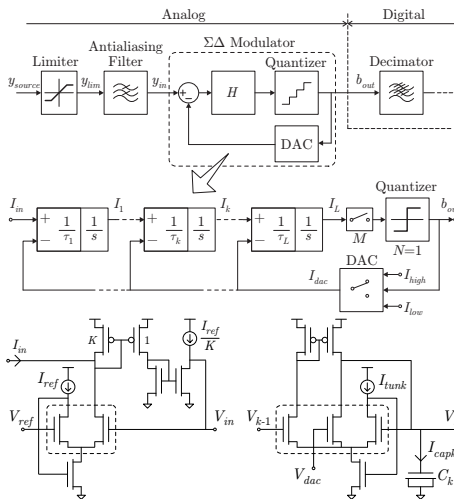
- ▶ Industrial product:






A 1V 300 μ A 1.2 μ m CMOS
analog hearing-aid-on-chip

Oversampling $\Sigma\Delta$ A/D Converters



- ▶ CMOS log-domain techniques
- ▶ Subthreshold operation
- ▶ All-MOS implementation

Oversampling $\Sigma\Delta$ A/D Converters

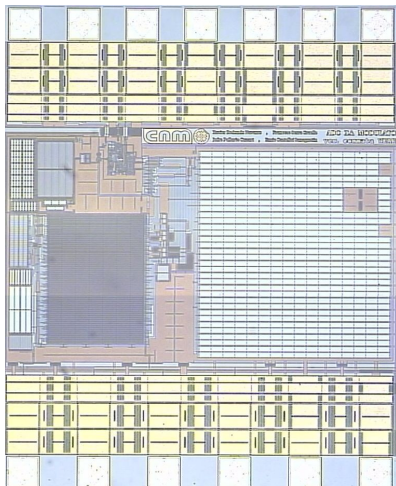
2000-01 FEDER-1FD97-2351

*Design of a CMOS
Low-Power Digital
Biophone*

2000-02 CICYT-TIC99-1084

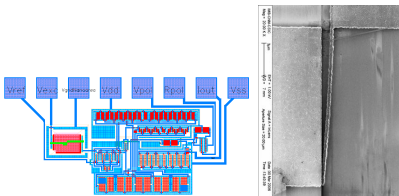
*CMOS Circuit
Techniques for Analog
Subsystems in Digital
Hearing Aids*

A 1.2V 100 μ W
0.35 μ m MOS-only
10/12-bit 8KHz $\Sigma\Delta$ ADC



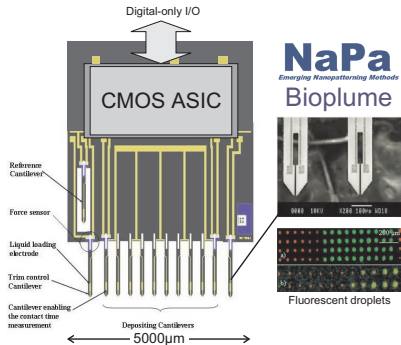
Sensor Interface for N/MEMS

2003-06 **NMP4-CT-2003-500120** *Emerging Nanopatterning Methods*



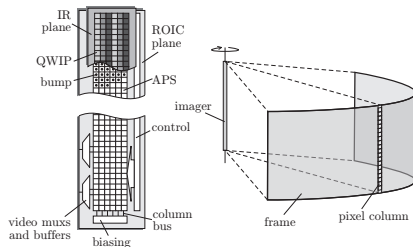
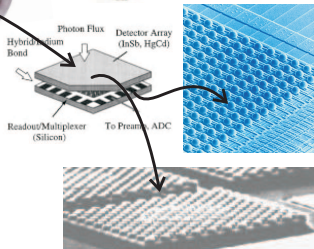
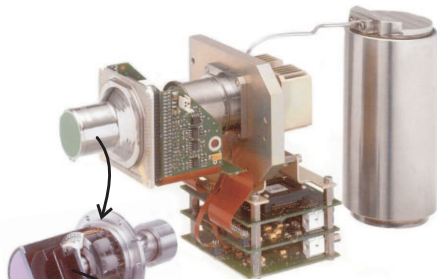
In-house $2.5\mu\text{m}$ CMOS
read-out circuit
for MEMS resonator

An integrated
fluidic system
for nano-dispensing



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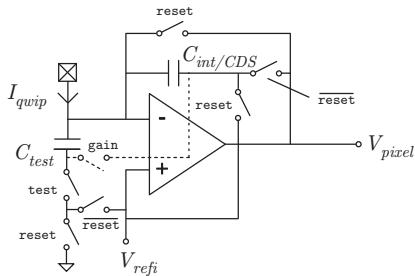
Cryogenic IR Scanning Imager



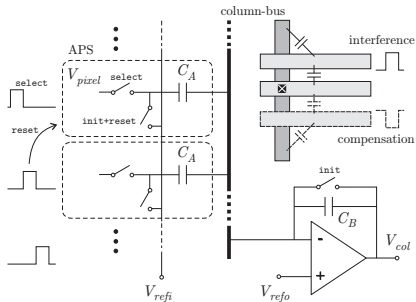
- ▶ QWIP sensors
- ▶ Low-current signal ($\sim 5\text{nA}$)
- ▶ Cryogenic temperature (77K)
- ▶ Small pixel size ($100\mu\text{m} \times 50\mu\text{m}$)
- ▶ 500×12 FPA
- ▶ **Complex** APS (CDS+test+prog)
- ▶ High-speed video streaming (60ns/s)
- ▶ Hybrid packaging (**high capacitance**)

Cryogenic IR Scanning Imager

- ▶ Novel SC techniques for **compact APS** + **low-power video**:



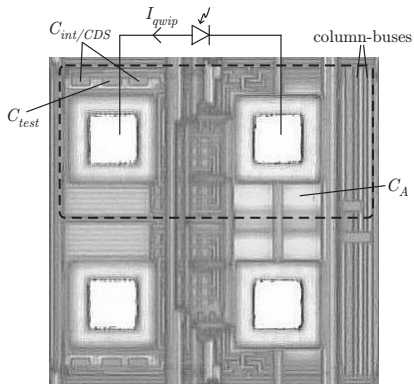
- ▶ Single-cap integration+CDS
- ▶ Built-in test
- ▶ Gain programability



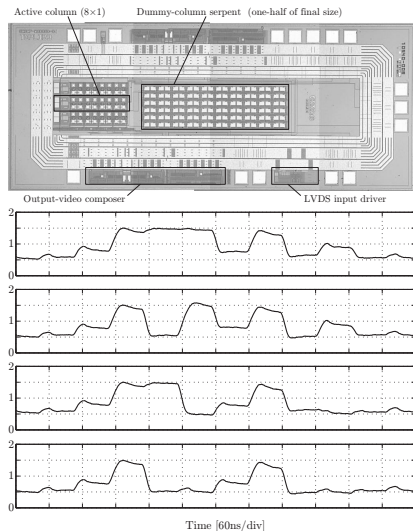
- ▶ Analog charge-multiplexing
- ▶ Pseudo Class-AB buffering

Cryogenic IR Scanning Imager

- ▶ Library driven research:



$50\mu\text{m} \times 100\mu\text{m}$ APS cell



Cryogenic IR Scanning Imager

- ▶ Cryogenic specific **MOSFET modeling** (CNM \leftrightarrow AMS)
- ▶ Industrial product in **standard CMOS 2P 3M** technology:



2002-04 **DN-8644 SIRIO**
*A low-power CMOS
 ROIC for cryogenic
 tri-color
 quantum-well IR
 photo-sensors*

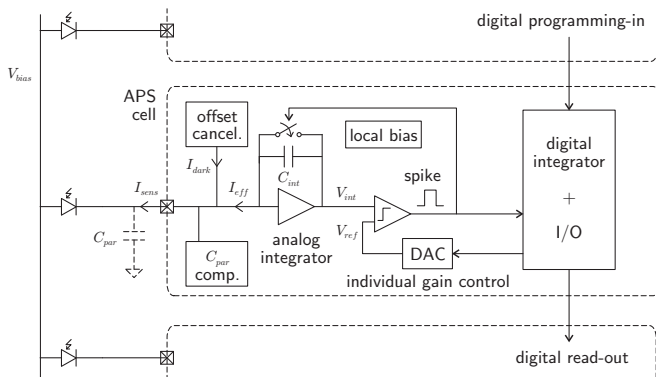


Indra

Pixel array size	500×12	pixel ²
Pixel pitch	50	μm
Pixel size	50×100	μm ²
Temperature operation	77	K
Integration time	15.6	μs
Video sampling	60	ns/pixel
Video resolution	10	bit
Pixel oversampling	4	times
Typical frame	640×500@100	pixel ² @fps
Supply voltage	3.3	V
Power consumption	210	mW
CMOS technology	0.35	μm
Silicon Area	25×2	mm ²
Complexity	~250K	devices

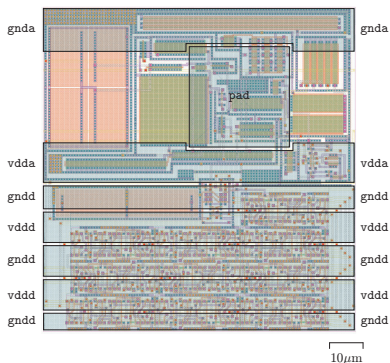
Room-Temperature IR Digital FPA Imager

- ▶ A **self-biased** and **FPN-compensated** digital APS:



... with pixel built-in asynchronous integrating **A/D converter**.

Room-Temperature IR Digital FPA Imager

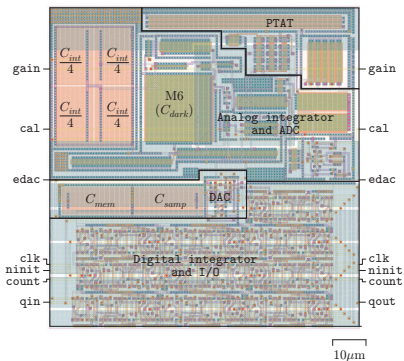


2005-06 DN-8835 SEADIR

A modular and digital CMOS imager for hybrid focal plane arrays of IR sensors

Dark current range	0.2-5	μA
Dark current retention	1-10	s
Max. input capacitance	15	pF
Signal range	1-1000	nA
Integration time	1	ms
Programming/read-out speed	10	Mbps
Supply voltage	3.3	V
Power consumption	<1	μW
Biasing deviations ($\pm\sigma$)	± 15	%
Total Silicon area	100x100	μm^2

Room-Temperature IR Digital FPA Imager



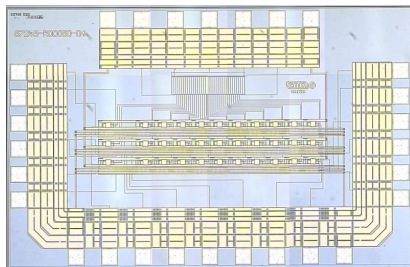
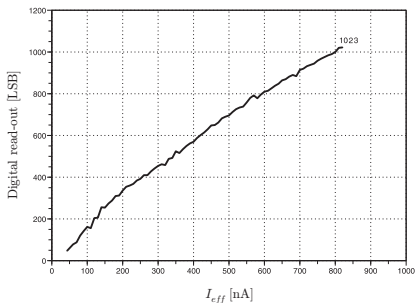
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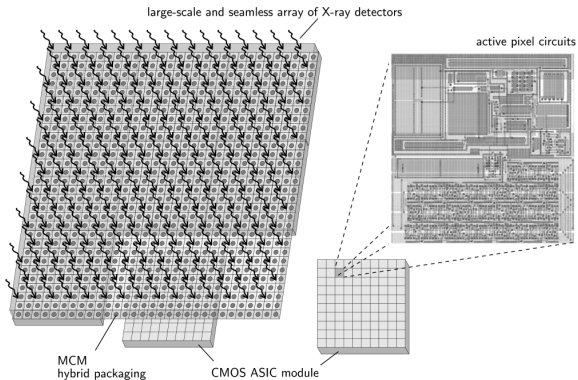
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Room-Temperature IR Digital FPA Imager

- ▶ Test vehicle implemented
- ▶ $0.35\mu\text{m}$ 2P 4M CMOS technology



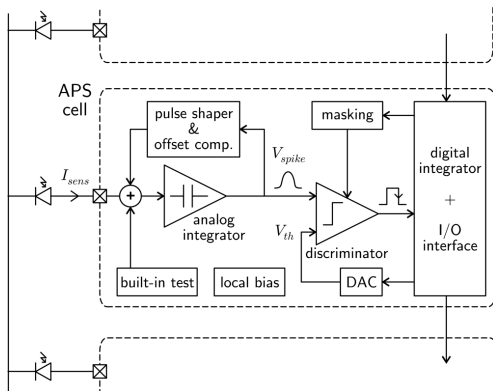
Large-Scale and Modular X-Ray Digital FPA Imager



- ▶ $6 \times 6 \text{cm}^2$ $800 \times 800 \text{pix}$ ($>0.5 \text{Mpix}$)
seamless X-ray images
- ▶ True modularity
- ▶ High flexibility
- ▶ Improved IC yield & costs
- ▶ Advanced in-house MCM packaging

Large-Scale and Modular X-Ray Digital FPA Imager

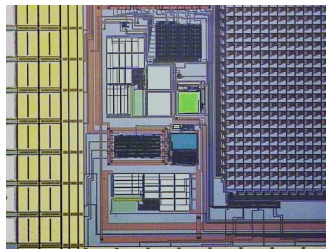
- ▶ Based on **photon counting** digital APS cells:



2006-07 **FIT-330101-2005-4 PFCP** A new integrated circuit and electronic system for capturing radiology images

Low-Power and RF Imagers for Optical Character Recognition

- ▶ **Built-in** sensor FPA
- ▶ Digital **OCR**
- ▶ **RF** communications
- ▶ **Battery** powered
- ▶ $0.35\mu\text{m}$ 2P 4M CMOS technology
- ▶ Industrial product

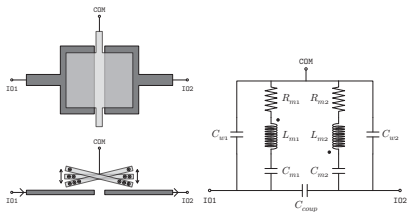
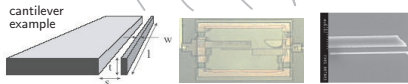
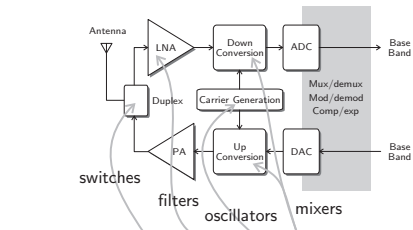


2003-05 **FIT-070000-2003-968**
Telecontadores
*A low-power and compact
OCR system for remote water
metering*

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Very Low-Power Mixed CMOS/NEMS RF Transceivers

- ▶ **High- Q** and **low-power** NEMS resonators
- ▶ **NEMS device** modeling and CMOS interface
- ▶ 0.35 μm 4M RF CMOS technology



2003 **CICYT-TIC02-1981**
Radio frequency CMOS integrated receivers for hearing-aids-on-chip

2004-06 **CICYT-TIC03-07237**
Low-power NEMS and CMOS systems for signal sensing and processing in portable applications



Very Low-Voltage and Low-Power Bluetooth Frontend

- ▶ Low End Extension (**LEE**) open standard
- ▶ **1V** battery powered
- ▶ Supply life **>1 year**
- ▶ $0.18\mu\text{m}$ 6M RF CMOS technology
- ▶ Application to networks of **sensors**

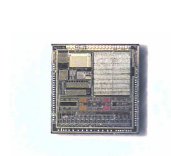
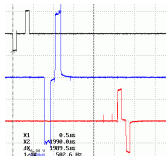
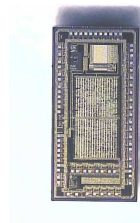
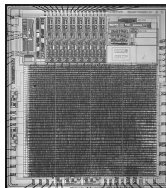


2006-07 **BluLite** SEIKO-EPSON industrial project

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Implantable SoC for multi-channel neural processing

- ▶ Transcutaneous **RF-coupling** link for **supply** and digital **communications**
- ▶ Low-power SoC
- ▶ Neural **recording** and **stimulation**
- ▶ $0.8\mu\text{m}$ and $0.35\mu\text{m}$ high-voltage CMOS technologies
- ▶ Applications:
 - ▶ Restoring mobility in SCI people
 - ▶ Control of artificial prosthesis



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What is next?

Emerging research on...

- ☯ **Heterogeneous** systems (sensors, NEMS, CMOS)
- ▮ Distributed and **parallel** processing (inter/intra-IC)
- ⚡ **Energy scavenging** (battery-less, very low-power)
- 📦 **Packaging** optimization (RF, sensors, stacked MCM)